

Title (en)
Planar element and method for the production thereof

Title (de)
Flächiges Element und Verfahren zum Herstellen desselben

Title (fr)
Élément plat et procédé pour le produire

Publication
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Application
EP 12189491 A 20080527

Priority
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Abstract (en)
[origin: WO2008145341A2] The aim of the invention is to design a planar element (100) and devise a method for producing such planar elements (100) in such a way that said planar element (100) is easy and inexpensive to produce and allows remarkable optical effects to be obtained. Said aim is achieved by applying at least one coating (30) to at least one area or side of at least one support substrate (10), especially at least one support plate.

IPC 8 full level
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